# Electric field enhancement of the superconducting spin-valve effect via strain-transfer across a ferromagnetic/ferroelectric interface

Tomohiro Kikuta<sup>1</sup>, Sachio Komori<sup>1\*</sup>, Keiichiro Imura<sup>1,2</sup>, Tomoyasu Taniyama<sup>1\*</sup>

<sup>1</sup>Department of Physics, Nagoya University, Furo-cho, Chikusa-ku, Nagoya 464-8602, Japan <sup>2</sup>Institute of Liberal Arts and Sciences, Nagoya University, Nagoya 464-8601, Japan

\*komori.sachio.h0@f.mail.nagoya-u.ac.jp

\*taniyama.tomo@nagoya-u.jp

In a ferromagnet/superconductor/ferromagnet (F/S/F) superconducting spin-valve (SSV), a change of the magnetization alignment of the two F layers modulates the critical temperature ( $T_c$ ) of the S layer. The  $T_c$ -switching (the SSV effect) is based on the interplay between superconductivity and magnetism. Fast and large resistive switching associated with the  $T_c$ -switching is suitable for nonvolatile cryogenic memory applications. However, external magnetic field-based operation of SSVs is hindering their miniaturization, and therefore, electric field control of the SSV effect is desired. Here, we report epitaxial growth of a La<sub>0.67</sub>Ca<sub>0.33</sub>MnO<sub>3</sub>/YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>/La<sub>0.67</sub>Ca<sub>0.33</sub>MnO<sub>3</sub> SSV on a piezo-electric [Pb(Mg<sub>0.33</sub>Nb<sub>0.67</sub>)O<sub>3</sub>]<sub>0.7</sub>-[PbTiO<sub>3</sub>]<sub>0.3</sub> (001) substrate and demonstrate electric field control of the SSV effect. Electric field-induced strain-transfer from the piezo-electric substrate increases the magnetization and  $T_c$  of the SSV, and leads to an enhancement of the magnitude of  $T_c$ -switching. The results are promising for the development of magnetic-field-free superconducting spintronic devices, in which the S/F interaction is not only sensitive to the magnetization alignment but also to an applied electric field.

The field of spintronics has emerged and rapidly developed following the discovery of the giant magnetoresistance (GMR) effect in a multilayer of a ferromagnet (F) and a nonmagnetic metal (N)<sup>1,2</sup>. Resistive switching of a spin-valve (i.e., a F/N/F trilayer)<sup>3,4</sup> is a basis of the modern spintronic technology and is based on the GMR effect: the electrical resistance increases at the antiparallel (AP) magnetization alignment of the two F layers compared to the parallel (P) alignment due to spin-dependent scattering of spin-polarized electrons. Numerous efforts have been undertaken to decrease the size and energy consumption of spin-valve-based logic and memory devices, and electric field control of ferromagnetism<sup>5,6</sup> and magnetic anisotropy<sup>7–9</sup>, which does not require an external magnetic field or electric currents for the resistive switching of spin-valves, is emerging as a promising technology.

Inserting a superconductor (S) instead of N in a spin-valve realizes a F/S/F superconducting spin-valve (SSV). A SSV is compatible with cryogenic electronics in which self-heating that changes properties of superconducting circuits needs to be suppressed. In addition to the normal state resistance of S, the critical temperature ( $T_c$ ) of S is controllable by the magnetization alignment in a SSV<sup>10–12</sup>. Although the mechanism of  $T_c$ -switching in SSVs depends on material combinations and is complicated, it is broadly categorized into three effects: magnetic exchange field effect<sup>13–15</sup>, spin scattering effect<sup>16,17</sup> and stray field effect<sup>18,19</sup>. For a SSV with an *s*-wave S,  $T_c$ -switching is observed when the S layer thickness ( $d_s$ ) is either comparable to or thinner than the superconducting coherence length ( $\zeta$ )<sup>13–15</sup>. However, in a SSV with a *d*-wave S,  $T_c$ -switching is observed up to the length scale of  $d_s \approx 100 \zeta^{20}$ , which may be due to the nodal superconducting gap with an effectively long  $\zeta$ , enabling  $T_c$ -switching of a relatively thick *d*-wave S with  $T_c$  close to the bulk value.  $T_c$ -switching of a SSV (the SSV effect) can be used for cryogenic memory devices, which are compatible with energy-efficient superconducting digital circuits and quantum computing circuits<sup>21–23</sup>. However, similar to conventional spin-valves, a technological breakthrough is necessary to realize small devices that do not require external magnetic fields or electric currents.

Here, we report epitaxial growth of a La<sub>0.67</sub>Ca<sub>0.33</sub>MnO<sub>3</sub>/YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>/La<sub>0.67</sub>Ca<sub>0.33</sub>MnO<sub>3</sub> (LCMO/YBCO/LCMO) SSV on a [001]-oriented [Pb(Mg<sub>0.33</sub>Nb<sub>0.67</sub>)O<sub>3</sub>]<sub>0.7</sub>-[PbTiO<sub>3</sub>]<sub>0.3</sub> (PMN-PT) substrate and demonstrate a reversible electric field control of the SSV effect. The magnitude of  $T_c$ -switching is enhanced by up to 6% via electric field-induced strain-transfer from the piezo-electric PMN-PT substrate. The result is promising for the development of electric field controllable superconducting spintronic devices.

A LCMO(100 nm)/YBCO(15 nm)/LCMO(50 nm) SSV was epitaxially grown on a commercially available [001]oriented PMN-PT substrate by pulsed laser deposition (the fourth harmonic of a Q-switched Nd:YAG laser; wavelength  $\lambda = 266$  nm). The substrate was preannealed at 633°C for 1 hour and a 20-nm-thick SrTiO<sub>3</sub> (STO) buffer layer was grown at the same temperature to prevent the reaction between the substrate and the SSV. The SSV was subsequently grown at 780 °C in 300 mTorr of flowing oxygen. The laser fluence is 0.25 J cm<sup>-2</sup> for YBCO and 0.5 J cm<sup>-2</sup> for LCMO and the laser frequency is 10 Hz. After the growth, the SSV was post-annealed at 500°C for 1 hour in 600 Torr of oxygen. In-plane electrical resistance (*R*) measurements using a current (*I*) of 100-1000  $\mu$ A were performed in a Gifford-McMahon cryogen-free system using a four-terminal electrical setup with Au (30 nm)/Ti (5 nm) contacts on the SSVs. A Au/Ti contact was also deposited at the bottom of the substrate to apply an electric field. *R* was measured as a function of the in-plane magnetic field (*H*), temperature (*T*), and electric field (*E*). *H* was applied parallel to *I*, and *E* was applied along the [001] direction of PMN-PT at room temperature prior to low temperature measurements. Care was taken to ensure that the leakage current (typically less than 10 nA) has no effect on *T<sub>c</sub>* and the resistive switching. The magnetization (*M*) was measured using a Quantum Design Magnetic Property Measurement System.

We first discuss a magneto-elastic coupling between LCMO and PMN-PT. Figure 1(a) shows a schematic illustration of the polarization directions and strain of PMN-PT with *E* along the [001] direction. The polarization along the [111], [111], [111], and [111] directions induced by *E* leads to a decrease of the *a*- and *b*-axis lattice constants and an increase of the *c*-axis lattice constant. Since the polarization is symmetric with respect to the polarity of *E*, a similar change of the lattice constants is induced for *E* along the [001] direction. Figure 1(b) shows out-of-plane x-ray diffraction data of a LCMO(50 nm)/STO(20 nm)/PMN-PT control sample, from which we estimate the

pseudocubic *c*-axis lattice constant of the LCMO layer to be 3.834 Å at E = 0, which is smaller than that of bulk LCMO (3.880Å<sup>24</sup>), indicating the presence of a lattice mismatch-induced tensile strain along the in-plane in the LCMO layer. By applying E = 4 kV/cm, the *c*-axis lattice constant of LCMO increases by 0.002 Å (0.052%), suggesting that the tensile strain along the in-plane is partially relaxed by strain transfer from PMN-PT. The change of the lattice constant of the LCMO layer is comparable to that reported for PMN-PT at 4 kV/cm (about 0.05%<sup>25</sup>), meaning that the electric field-induced compressive strain along the in-plane is coherently transferred from the PMN-PT substrate to the LCMO layer. Figure 1(c) shows M(T) curves of the LCMO/STO/PMN-PT sample at H = 5000 Oe for E = 0 and 4 kV/cm. The magnetization of LCMO is increased by 10 emu/cm<sup>3</sup> (5.1%) at E = 4 kV/cm compared to E = 0, implying that the electric field-induced compressive strain along the in-plane leads to a shorter Mn-Mn bond length and a stronger double exchange interaction in LCMO. Similar electric field modulations of the magnetization have been reported for manganite/ferroelectric heterostructures and several mechanisms have been proposed (e.g., strain-transfer<sup>25–27</sup>, carrier doping<sup>25,28</sup>, and oxygen migration<sup>29</sup>). We note that the 20-nm-thick STO buffer layer between LCMO and PMN-PT in our sample is likely to suppress the carrier doping effect and the oxygen migration effect and therefore, the strain-transfer is the most likely origin of the electric field enhancement of the magnetization.

We next discuss a LCMO(100 nm)/YBCO(15 nm)/LCMO(50 nm) SSV grown on a PMN-PT (001) substrate. Figure 2(a) shows out-of-plane x-ray diffraction data, which confirm *c*-axis oriented growth of the SSV and the absence of impurity phases. The *c*-axis lattice constants of LCMO and YBCO are determined to be 3.869Å and 11.55Å, respectively. Rocking curves around the diffraction peaks of the LCMO (002) and the YBCO (006) show narrow full width at half maximum values of 0.208° and 0.196°, respectively, confirming that the SSV is highly oriented along the [001]-axis of the PMN-PT substrate.

In Fig. 3(a), we plot R(T) of the SSV near the superconducting transition at E = 0 and 4 kV/cm, which shows a parallel shift of the R(T) curve indicating an electric field enhancement of  $T_c$  down to  $R/R_N \approx 10^{-6}$ , where  $R_N$  is the normal state resistance at the onset temperature of the superconducting transition. An enhancement of  $T_c$  via strain-transfer from a (001)-oriented PMN-PT substrate has been reported for YBCO thin films<sup>30</sup>. The  $T_c$  enhancement induced by a compressive strain along the in-plane is consistent with a  $T_c$  enhancement in YBCO single crystals under uniaxial pressure along the *b*-axis<sup>31</sup>. Figure 3(b) shows R(H) curves at 36 K ( $\approx T_c$ ) for E = 0 and 4 kV/cm, where R is normalized at the minimum value. The sharp peaks at  $H \approx \pm 200$  Oe indicate a decrease in  $T_c$  near the antiparallel magnetization alignment of the two LCMO layers. Since the sign of the resistive switching is opposite to that of the magnetic exchange field effect<sup>16,17</sup> and the stray field effect is negligibly small [see Fig. S2(b) within the Supplemental Material], the switching is likely due to the spin-scattering effect reported for the similar SSVs consisting of YBCO and LCMO<sup>32–34</sup>. The magnitude of the peaks of the normalized R is enhanced by 33% by applying E = 4 kV/cm.

To estimate the effective change in  $T_c$  resulting from the change of the magnetization alignment ( $\Delta T_c$ ), we compare the magnitude of the resistance peak ( $\Delta R$ ) from the R(H) curve with the slope of the superconducting transition from the R(T) curve [i.e.,  $\Delta T_c$  is estimated from the relation  $\Delta R = \alpha \Delta T_c$ , where  $\alpha$  is the slope of the R(T) curve at the temperature of the R(H) measurement]. Figure 3(c) shows the temperature dependence of  $\Delta T_c$  at E = 0 and 4 kV/cm. The  $\Delta T_c(T)$  curves show a peak at 31 K for E = 0 and 32 K for 4 kV/cm, meaning that the magnitude of the SSV effect is temperature-dependent. The opening of the superconducting gap with decreasing temperature decreases the density of quasiparticles responsible for the spin-scattering while the density of Cooper pairs decreases with increasing temperature. Hence, the quasiparticle-mediated pair breaking effect is maximized at a certain temperature and this results in the peak feature of the  $\Delta T_c(T)$  curves. The electric field-induced shift of the  $\Delta T_c(T)$  curve by about 1 K is due to the shift of  $T_c$  [shown in Fig. 3(a)]. The maximum  $\Delta T_c$  at E = 4 kV/cm (700 mK) is higher than that at E = 0 (660 mK), meaning that the SSV effect is enhanced by 6% by applying an electric field.

Regardless of the origin of the SSV effect,  $\Delta T_c$  can be enhanced by either increasing the magnetization or increasing the maximum magnetization misalignment angle of the two F layers. We note that the coercive fields of the two LCMO layers in our SSVs are comparable. Therefore, the magnetization misalignment angle at *H* corresponding to the *R* peak in *R*(*H*) is less than 180° and the misalignment angle can be increased if the electric field-induced strain increases the difference of the coercive fields of the two LCMO layers. However, a broadening of the resistive switching in *R*(*H*) is not observed at *E* = 4 kV/cm, suggesting that the coercivities are not sensitive to the electric field. Therefore, the likely origin of the enhancement of  $\Delta T_c$  is the enhanced magnetization of the two LCMO layers. If this is the case, a similar enhancement of the SSV effect should be observed also in other SSVs with other  $T_c$ switching mechanisms (e.g., the magnetic exchange effect<sup>13–15,20,35</sup> and the stray field effect<sup>18,19</sup>) and the enhancement can be amplified with decreasing thickness of the S layer, which could be subjects of future investigation.

In conclusion, we have prepared a LCMO/YBCO/LCMO epitaxial SSV on a piezoelectric PMN-PT substrate and demonstrated an electric field enhancement of the SSV effect. Upon application of an electric field, the compressive strain along the in-plane is induced in the SSV and the magnetization of LCMO and  $T_c$  of YBCO are enhanced accordingly. These led to an enhanced magnitude of the  $T_c$ -switching. The electric field control of the S/F interaction demonstrated in this work can be potentially applied to various S/F multilayers including magnetic Josephson junctions and is promising for the development of size-scalable superconducting spintronic devices.

The authors acknowledge funding from JST CREST Grant (No. JPMJCR18J), JSPS KAKENHI Grant (No. 21H04614, No. 20K23374, and No. 23KK0086), and JSPS Bilateral Joint Research Projects Grant (No. JPJSBP120197716). S.K. acknowledges funding from JST FOREST Grant (No. JPMJFR212V).



FIG. 1. (a) Schematic illustration of the polarization and lattice strains in PMN-PT with an electric field along the [001] direction. (b) Out-of-plane x-ray diffraction pattern and (c) M(T) for E = 0 (red curves) and 4 kV/cm (blue curves) for a LCMO(50 nm)/STO(20 nm)/PMN-PT control sample. M(T) was measured during cooling at H = 5000 Oe. The inset in (c) shows the magnified M(T) curves.



FIG. 2. (a) Out-of-plane x-ray diffraction pattern of LCMO(100 nm)/YBCO(15 nm)/LCMO(50 nm)/STO(20 nm) on a [001]-oriented PMN-PT substrate. Rocking curves on the (b) LCMO (002) and (c) YBCO (006) peaks showing full width at half maximum values of 0.208° and 0.196°, respectively.



FIG. 3. (a) R(T), (b) R(H), and (c)  $\Delta T_c(T)$  curves for

LCMO(100 nm)/YBCO(15 nm)/LCMO(50 nm)/STO(20 nm)/PMN-PT at E = 0 (red curves) and 4 kV/cm (blue curves). The inset in (a) shows a schematic diagram of the SSV device. The solid and dashed curves in (b) indicate negative and positive *H*-sweeps, respectively.

<sup>1</sup> M.N. Baibich, J.M. Broto, A. Fert, F.N. Van Dau, F. Petroff, P. Eitenne, G. Creuzet, A. Friederich, and J. Chazelas, Phys. Rev. Lett. **61**, 2472 (1988).

- <sup>2</sup> G. Binasch, P. Grünberg, F. Saurenbach, and W. Zinn, Phys. Rev. B **39**, 4828 (1989).
- <sup>3</sup> B. Dieny, V.S. Speriosu, B.A. Gurney, S.S.P. Parkin, D.R. Wilhoit, K.P. Roche, S. Metin, D.T. Peterson, and S. Nadimi, J. Magn. Magn. Mater. **93**, 101 (1991).
- <sup>4</sup> B. Dieny, V.S. Speriosu, S. Metin, S.S.P. Parkin, B.A. Gurney, P. Baumgart, and D.R. Wilhoit, J. Appl. Phys. **4779**, 4774 (1991).
- <sup>5</sup> Y.H. Chu, L.W. Martin, M.B. Holcomb, M. Gajek, S.J. Han, Q. He, N. Balke, C.H. Yang, D. Lee, W. Hu, Q. Zhan,
- P.L. Yang, A. Fraile-Rodríguez, A. Scholl, S.X. Wang, and R. Ramesh, Nat. Mater. 7, 478 (2008).
- <sup>6</sup>S.M. Wu, S. Cybart, P. Yu, M.D. Rossell, J.X. Zhang, R. Ramesh, and R.C. Dynes, Nat. Mater. 9, 756 (2010).
- <sup>7</sup> T. Maruyama, Y. Shiota, T. Nozaki, K. Ohta, N. Toda, M. Mizuguchi, A.A. Tulapurkar, T. Shinjo, M. Shiraishi, S.
- Mizukami, Y. Ando, and Y. Suzuki, Nat. Nanotechnol. 4, 158 (2009).
- <sup>8</sup> T. Nozaki, T. Yamamoto, S. Miwa, and M. Tsujikawa, Micromachines 10, 327 (2019).
- <sup>9</sup> T. Taniyama, J. Phys. Condens. Matter 27, 504001 (2015).
- <sup>10</sup> S. Oh, D. Youm, and M.R. Beasley, Appl. Phys. Lett. **71**, 2376 (1997).
- <sup>11</sup> L.R. Tagirov, Phys. Rev. Lett. 83, 2058 (1999).
- <sup>12</sup> A.I. Buzdin, Vedyayev, A, V, and Ryzhanova, N, V, Europhys. Lett. 48, 686 (1999).
- <sup>13</sup> P.G. De Gennes, Phys. Lett. **23**, 10 (1966).
- <sup>14</sup> B. Li, N. Roschewsky, B.A. Assaf, M. Eich, M. Epstein-Martin, D. Heiman, M. Münzenberg, and J.S. Moodera, Phys. Rev. Lett. **110**, 097001 (2013).
- <sup>15</sup> Y. Zhu, A. Pal, M.G. Blamire, and Z.H. Barber, Nat. Mater. 16, 195 (2016).
- <sup>16</sup> A. Singh, C. Sürgers, R. Hoffmann, H. V. Löhneysen, T. V. Ashworth, N. Pilet, and H.J. Hug, Appl. Phys. Lett. **91**, 152504 (2007).
- <sup>17</sup> A.Y. Rusanov, S. Habraken, and J. Aarts, Phys. Rev. B 73, 060505(R) (2006).
- <sup>18</sup> J. Zhu, X. Cheng, C. Boone, and I.N. Krivorotov, Phys. Rev. Lett. **103**, 027004 (2009).
- <sup>19</sup> D. Stamopoulos, E. Manios, and M. Pissas, Phys. Rev. B 75, 184504 (2007).
- <sup>20</sup> A. Di Bernardo, S. Komori, G. Livanas, G. Divitini, P. Gentile, M. Cuoco, and J.W.A. Robinson, Nat. Mater. **18**, 1194 (2019).
- <sup>21</sup> I.M. Dayton, T. Sage, E.C. Gingrich, M.G. Loving, T.F. Ambrose, N.P. Siwak, S. Keebaugh, C. Kirby, D.L. Miller,
- A.Y. Herr, Q.P. Herr, and O. Naaman, IEEE Magn. Lett. 9, 3301905 (2018).
- <sup>22</sup> I.I. Soloviev, N. V Klenov, S. V Bakurskiy, M.Y. Kupriyanov, A.L. Gudkov, and A.S. Sidorenko, Beilstein J.

Nanotechnol. 8, 2689 (2017).

- <sup>23</sup> Y. He, J. Li, Q. Wang, H. Matsuki, and G. Yang, Adv. Devices Instrum. 4, 0035 (2023).
- <sup>24</sup> C.S. Hong, W.S. Kim, E.O. Chi, K.W. Lee, and N.H. Hur, Chem. Mater. **12**, 3509 (2000).
- <sup>25</sup> Z.G. Sheng, J. Gao, and Y.P. Sun, Phys. Rev. B 79, 174437 (2009).
- <sup>26</sup> W. Eerenstein, M. Wiora, J.L. Prieto, J.F. Scott, and N.D. Mathur, Nat. Mater. 6, 348 (2007).
- <sup>27</sup> C. Thiele, K. Dörr, O. Bilani, J. Rödel, and L. Schultz, Phys. Rev. B 75, 054408 (2007).

- <sup>28</sup> H. Lu, T.A. George, Y. Wang, I. Ketsman, J.D. Burton, S. Ryu, D.J. Kim, J. Wang, C. Binek, P.A. Dowben, A. Sokolov, E.Y. Tsymbal, and A. Gruverman, Appl. Phys. Lett. **100**, 232904 (2012).
- <sup>29</sup> K. Imura, S. Ishikawa, S. Komori, and T. Taniyama, Appl. Phys. Lett. **122**, 202402 (2023).
- <sup>30</sup> P. Pahlke, S. Trommler, B. Holzapfel, L. Schultz, and R. Hühne, J. Appl. Phys. **113**, 123907 (2013).
- <sup>31</sup> W.H. Fietz, K.P. Weiss, and S.I. Schlachter, Supercond. Sci. Technol. 18, S332 (2005).
- <sup>32</sup> V. Peña, Z. Sefrioui, D. Arias, C. Leon, J. Santamaria, J.L. Martinez, S.G.E. Te Velthuis, and A. Hoffmann, Phys. Rev. Lett. **94**, 057002 (2005).
- <sup>33</sup> N.M. Nemes, M. García-Hernández, S.G.E. Te Velthuis, A. Hoffmann, C. Visani, J. Garcia-Barriocanal, V. Peña, D. Arias, Z. Sefrioui, C. Leon, and J. Santamaría, Phys. Rev. B **78**, 094515 (2008).
- <sup>34</sup> N.M. Nemes, C. Visani, C. Leon, M. Garcia-Hernandez, F. Simon, T. Fehér, S.G.E. te Velthuis, A. Hoffmann, and J. Santamaria, Appl. Phys. Lett. **97**, 032501 (2010).

<sup>35</sup> S. Komori, A. Di Bernardo, A.I. Buzdin, M.G. Blamire, and J.W.A. Robinson, Phys. Rev. Lett. **121**, 077003 (2018).

### Supplemental Material for

# Electric field enhancement of the superconducting spin-valve effect via strain-transfer across a ferromagnetic/ferroelectric interface

Tomohiro Kikuta<sup>1</sup>, Sachio Komori<sup>1\*</sup>, Keiichiro Imura<sup>1,2</sup>, Tomoyasu Taniyama<sup>1\*</sup>

<sup>1</sup>Department of Physics, Nagoya University, Furo-cho, Chikusa-ku, Nagoya 464-8602, Japan <sup>2</sup>Institute of Liberal Arts and Sciences, Nagoya University, Nagoya 464-8601, Japan

\*komori.sachio.h0@f.mail.nagoya-u.ac.jp

\*taniyama.tomo@nagoya-u.jp

#### 1. X-ray diffraction pattern of a YBCO/LCMO bilayer on PMN-PT(001)

Figure S1 shows out-of-plane x-ray diffraction data from

STO(5 nm)/YBCO(15 nm)/LCMO(50 nm)/STO(20 nm)/PMN-PT, confirming *c*-axis oriented growth of YBCO and LCMO. We note that the 5-nm-thick STO capping layer was deposited to prevent out-diffusion of oxygen from YBCO and the 20-nm-thick STO buffer layer was deposited to prevent the reaction between LCMO and PMN-PT.



FIG. S1. Out-of-plane x-ray diffraction pattern of a YBCO(15 nm)/LCMO(50 nm) bilayer on a PMN-PT(001) substrate.

#### 2. Superconducting properties of a YBCO/LCMO bilayer on PMN-PT(001)

Figure S2(a) shows R(T) curves of the YBCO/LCMO bilayer at E = 0 and 4 kV/cm.  $T_c$  of the bilayer is higher than that of the superconducting spin-valve in the main manuscript. This is probably due to the absence of the growth process of the 100-nm-thick top LCMO layer causing out-diffusion of oxygen from YBCO. Since  $T_c$  of the bilayer is close to the optimum value, the electric field enhancement of  $T_c$  is smaller than that observed for the superconducting spin-valve in the main manuscript. Figure S2(b) shows R(H) curves of the bilayer at 72 K ( $\approx T_c$ ) for E = 0 and 4 kV/cm. The monotonic increase of R with H is due to the field suppression of the superconductivity. The absence of the resistive switching near the coercive field ( $H \approx \pm 200$  Oe) suggests that the stray field effect from magnetic domain walls of LCMO is negligibly small.



FIG. S2. (a) R(T) and (b) R(H) at 72 K for a YBCO(15 nm)/LCMO(50 nm) bilayer on PMN-PT(001) at E = 0 (red curves) and 4 kV/cm (blue curves).